Low-Cost Energy-Efficient 3-D Nano-Spikes-Based Electric Cell Lysis Chips

Kashif Riaz, Siu-Fung Leung, Zhiyong Fan, Member, IEEE, and Yi-Kuen Lee, Member, IEEE

Abstract-Electric cell lysis (ECL) is a promising technique 1 to be integrated with portable lab-on-a-chip without lysing 2 agent due to its simplicity and fast processing. ECL is usually 3 limited by the requirements of high power/voltage and costly 4 fabrication. In this paper, we present low-cost 3-D nano-spikes-5 based ECL (NSP-ECL) chips for efficient cell lysis at low power 6 consumption. Highly ordered HAR NSP arrays with control-7 8 lable dimensions were fabricated on commercial aluminum foils through scalable and electrochemical anodization and etching. 9 The optimized multiple pulse protocols with minimized unde-10 sirable electrochemical reactions (gas and bubble generation), 11 common on micro parallel-plate ECL chips. Due to the scalability 12 of fabrication process, 3-D NSPs were fabricated on small chips 13 as well as on 4-in wafers. Phase diagram was constructed by 14 defining critical electric field to induce cell lysis and for cell lysis 15 saturation E_{sat} to define non-ECL and ECL regions for different 16 pulse parameters. NSP-ECL chips have achieved excellent cell 17 lysis efficiencies η_{lysis} (ca 100%) at low applied voltages (2 V), 18 2~3 orders of magnitude lower than that of conventional systems. 19 The energy consumption of NSP-ECL chips was 0.5-2 mJ/mL, 20 21 $3\sim9$ orders of magnitude lower as compared with the other methods (5J/mL-540kJ/mL). [2016-0305] 22

Index Terms—Nano-spikes, electric cell lysis chips, elec trochemical anodization and etching processes, electric field
 enhancement, energy-efficient, lab on chip.

I. INTRODUCTION

CELL LYSIS is an important step in sample preparation procedures and biopharmaceutical product extraction to release intracellular contents, i.e., DNA, RNA, hormones, vaccines, antibodies, recombinant proteins, and so forth. by disrupting cell membrane [1]–[6]. Economics of these procedures is greatly influenced by downstream processing steps, i.e., separation, purification, and so on. [1]. Sample preparation for molecular, protein and genomic diagnostic and analysis is time-consuming, labor intensive and costly process due

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to multiple steps and bulky instruments [4], [6]-[8]. Lab-36 on-a-chip (LOC) and micro total analysis system (μ -TAS) 37 are rapidly growing in different fields ranging from mole-38 cular/protein/genome diagnostic and analysis to the search 39 for life on Mars [9]-[13]. Due to recent developments in 40 micro/nanotechnologies, conventional bulky and costly sample 41 preparation processes can be scaled down and integrated into a 42 single compact, automated, and portable microsystem, LOC or 43 μ -TAS [4]–[12]. These microsystems have great promise due 44 to their simplicity, low cost, time efficiency, low consumption 45 of valuable reagents and biological samples [4]-[12]. 46

Numerous techniques have been employed for cell lysis on 47 integrated microsystems, LOC, or μ -TAS such as mechanical, 48 chemical, thermal, ultrasonic, optical, electrical, with their 49 unique advantages and limitations [2]-[7]. Mechanical cell 50 lysis (MCL) based on exerting localized high pressure, shear 51 stress, friction forces, compressive stress, on cell membrane 52 through micro-channels, filters, moving membranes, beads, 53 etc [2]–[5]. MCL integration on LOC is limited due to moving 54 parts and blockage of micro/nanochannels, gaps, filters by cell 55 debris [3]-[5]. Furthermore, due to cell debris micronization 56 into small fragments and non-selective release of products 57 through MCL; additional costly and time-consuming sepa-58 ration and purification steps are required [3]-[5]. Chemical 59 cell lysis (CCL) utilized lysis agents such as surfactants, 60 enzymes, detergents, etc., to dissolve cell membrane in 61 microfluidic channel network [2]-[5]. CCL methods are lim-62 ited due to pretreatment of lysing agents, purification of the 63 added agents for downstream processing, different protocols 64 for different samples and inherently slow due to complex 65 chemical processes [3]–[5]. Thermal cell lysis utilized high 66 temperatures and cyclic heating for cell lysis but not suitable 67 for portable LOC systems due to high power requirement for 68 heat generation and irreversible protein denaturation [3]-[5]. 69 Ultrasonic cell lysis is not suitable for LOC systems due 70 to complex instrumentation, excessive heat generation, and 71 inefficient power transmission to samples [2]-[5]. Intracellular 72 product yield greatly improved by increasing the intensity 73 of cell lysis methods mentioned above, but it also increases 74 micronization of cell debris and additional contaminants from 75 intracellular compartments [1]. This increases the produc-76 tion cost and processing time due to additional downstream 77 processing, i.e., separation, purification, etc. [1]. 78

Electric Cell lysis (ECL) is a physical method that has potential to overcome these limitations due to its simplicity, cost effectiveness, high efficiency, fast processing, easy miniaturization, applicability to diverse samples, and possible

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TABLE I Comparison of Micro/Nano Electric Cell Lysis Chips

Ref.	Electrode	Amplitude (V)	Duration	Efficiency (%)	Remarks
[39]	3D Au/Ti micro	~8.5	-	74	Low efficiency
[40]	Pt/Ti micro	10-40	-	<80	Bubble generation
[18]	3D Au/Cr micro	10	-	30	Low efficiency
[38]	MWCNT	40	-	~100	High voltage
[14]	Cr/Au micro	20	100 µs	90	High voltage
[41]	Cr/Au micro	10	-	80	Low efficiency
[42]	Cr/Au micro	10	-	80	Low efficiency
[43]	ITO micro	30	-	61	Low efficiency
[44]	Cr/Au micro	5-6	5-10 min.	>95	Longer time
[45]	3D carbon micro	130	400 ms	90	High voltage
[46]	Pt/Ta micro	20	0.5-2 s	~100	High voltage
Our work	3D Nano spikes	2	12ms	100±0.1	Low voltage High efficiency

integration with downstream processes as no lysis agents 83 required [2]–[6], [14]. ECL employs intense pulsed elec-84 tric field to induce irreversible nanopores on cell membrane 85 which leads to cell lysis [2], [3]. ECL has been proved 86 effective in avoiding complete cell disruption, micronization 87 of cell debris and contaminants from intracellular compart-88 ments by selectively lysing the cell membrane rapidly and 89 quickly [15]. Besides these advantages, ECL methods are 90 limited by high energy consumption (5-500 J/mL) and voltage 91 requirement (few tens of volts) as listed in Table 1 to achieve 92 critical electric field for cell lysis E_{CL} (kV/cm). To fulfill 93 these requirements, special costly and bulky power generators 94 are necessary. This is highly undesirable in portable LOC 95 applications [3], [4], [16]. Various designs have been proposed 96 to achieve E_{CL} at low voltages either by decreasing the 97 distance between electrodes or focusing electric field through 98 small constriction segments and structures in microchan-99 nels or micro-chambers [2]-[4], [17]. Most commonly used 100 2D planar electrodes suffer from uneven exposure of cells 101 to an electric field, resulting in low cell lysis efficiencies 102 η_{lysis} [3], [16]. 3D electrodes were designed to overcome this 103 drawback which showed higher η_{lysis} (30%) as compared to 104 2D electrodes (8%) [18]. However, the fabrication of 3D elec-105 trodes usually involves complex, time-consuming and costly 106 fabrication steps [19], [20]. 107

Direct current (DC) voltage is preferred as cell membrane experienced larger transmembrane potential (TMP) without lysing the intracellular components [3], [4], [17]. However, the voltage required to achieve electric field in kV/cm range usually lead to water electrolysis which may lead to gas bubble generation, extreme pH conditions and Joule

TABLE II Comparison of Electric Cell Lysis on Electrodes With and Without Nanostructures

Ref.	Nano-structures	Voltage requirement (V)	Without nano-structures (V)	Efficiency (%)
[38]	MWCNTs	40	85	100
[35]	CNTS	35	135	>95
[36]	CNTs	35	135	>95
[37]	CNTs	40	>90	100
[34]	Nano-gaped ITO electrodes	9	-	~90
this paper	3D Nano-spikes	2	>10	100±0.1

heating [3], [21]. Alternating current (AC) voltages have 114 been used to minimize these problems for on-chip ECL at 115 optimized frequencies [3], [4], [21]. Depending on applied 116 electric pulse amplitude, duration and number (usually high 117 for ECL), AC ECL techniques also suffer from gas bubble 118 generation, Joule heating, and pH variations [21]–[24]. These 119 undesirable phenomena resulted in the production of unwanted 120 electrolytic chemical compounds led to electrode degradation, 121 effects on thermo-sensitive intracellular contents, i.e., proteins 122 and on reaction kinetics of specific application [25]-[27]. 123 To avoid these drawbacks, subcellular sized constriction 124 structures were employed in a microchannel, so that maxi-125 mum potential drop was across the cell membrane trapped 126 in these structures instead of in the vicinity of the elec-127 trodes [28], [29]. The integration of these structures on 128 portable LOC is limited by complex and costly manufactur-129 ing steps, expensive equipment for micro/nanoflow, channel 130 blocking by cell debris and bubbles [3], [17], [25]-[27]. The 131 average electric current between the electrodes can also be 132 reduced by applying AC pulses with low amplitude and shorter 133 duration. However, pulse parameters should be optimized to 134 achieve high η_{lysis} in addition to the minimization of unde-135 sirable electrochemical reactions [21], [25], [30], [31]. Cell 136 lysis efficiencies were always a concern in previous reports 137 and η_{lvsis} were well below 100% in most of the methods 138 mentioned above [2], [3], [4] (Table 1). 139

High-aspect-ratio nano-structures (nano-tubes, nano-wires 140 etc.) were incorporated on electrodes to locally enhance 141 electric field intensity to cell membranes and used for cell 142 lysis [32]-[37]. The cell lysing results on these chips indi-143 cated that required voltage reduced as compared to electrodes 144 without nano-structures but still in the range of few tens 145 of volts [32]–[37] (Table 2). One of the bottlenecks in the 146 integration of nanostructures on microchips are the difficulties 147 in handling, aligning and positioning the nanostructures at 148 the exact desired location [46]. Furthermore, the fabrication 149 techniques employed are complex, costly, time-consuming and 150 non-reproducible [46]. It is highly desirable to establish sim-151 ple, inexpensive, reliable and scalable fabrication techniques 152 for fabrication of reproducible and aligned nanostructures to 153 be used in integrated portable LOC systems and potential mass 154 production [9], [46]-[48]. 155

In this work, we present a low-cost 3D nano-spike based ¹⁵⁶ electric cell lysis chip which employed self-aligned highly ¹⁵⁷

ordered 3D Aluminum (Al) nano-spike (NSP) arrays fabricated 158 through electrochemical anodization and etching (EA&E) 159 processes using anodic alumina membrane(AAM) as a tem-160 plate. 3D self-aligned highly ordered nano-structures were 161 fabricated using EA&E processes recently due to their sim-162 plicity, low cost, reproducibility, and scalability [49]. These 163 nano-structures showed enhanced performance in the field of 164 electronics, optoelectronic, photovoltaic, magnetism, medical, 165 and biology [49], [51]–[54]. Alumina is already recognized 166 as bio-compatible material and used in hip arthroplasty [55], 167 tissue engineering especially for skin replacement [56], bone 168 implant [57], and cell culture and proliferation [58]. 169

We developed an energy-efficient 3D nano-spikes based 170 electric cell lysis (NSP-ECL) chips for efficient cell lysis 171 at low energy consumption. NSP-ECL chips comprised of 172 highly-ordered high-aspect-ratio (λ) 3D Al NSP arrays with 173 controllable dimensions, i.e., length, L_{ns} , base radius, R_{ns} , 174 and pitch, P_{ns} (spike to spike distance). These optimized 175 aspect-ratio λ (= L_{ns}/R_{ns}) NSPs were fabricated on low-cost 176 commercial Al foils through simple, scalable, reproducible 177 and cost effective EA&E process. The electric field has been 178 localized at NSPs due to high λ with an enhancement factor 179 α . NSP-ECL chips have achieved high cell lysis efficiencies 180 η_{lysis} (100%) at more than ten times reduced pulse ampli-181 tudes (2 V) through localized electric field E_{NSP} as compared 182 to micron-distant parallel plate electric cell lysis (μ PPECL) 183 chips without NSPs. The employment of low-cost EA&E 184 fabrication process, optimized AC electric pulses with low 185 amplitudes (2 V), short durations (few milliseconds) and low 186 energy consumption (0.5-2 mJ/mL) minimized undesirable 187 electrochemical reactions, such as gas and bubble generation 188 on NSP-ECL chips. Due to the scalability of the fabrication 189 process, 3D NSPs were fabricated on small chips as well as 190 on wafers. 191

192 II. NANO-SPIKES BASED ELECTRIC CELL LYSIS SYSTEM

Schematic diagram of a nano-spikes based electric cell 193 lysis (NSP-ECL) system along with optical micrograph 194 of fabricated nano-spikes on an Al foil and packaged 195 NSP-ECL chip is shown Fig. 1. NSP-ECL chips consist 196 of 3D periodic NSP arrays fabricated on a low-cost commer-197 cial Al foil using nano-imprint lithography, electrochemical 198 processes, i.e., anodization and etching and MEMS technol-199 ogy. By controlling dimensions of NSPs, NSPs were fab-200 ricated with different aspect ratios λ (= L_{ns}/R_{ns}). Large 201 λ resulted in electric field enhancement E_{ns} at NSPs and 202 applied electric field E_a was enhanced with an enhancement 203 factor α . A PCI 6110 DAQ card (National Instrument, TX, 204 USA) and a Labview program were used to apply AC electric 205 pulses with adjustable pulse amplitudes V_a , durations t_p and 206 number P_n to NSP-ECL chips. An Olympus IX70 inverted 207 fluorescent microscope, and a QImaging Retiga 1300C digital 208 CCD camera (Burnaby, B.C., Canada) were used to acquire 209 a set of bright field and fluorescent micrographs before and 210 after ECL through an image capture card. Cell lysis efficiency 211 η_{lysis} were determined as functions of electric pulse parame-212 ters $(V_a, t_p \text{ and } P_n)$ and NSPs dimensions using these acquired 213 images through image processing. Due to E_{ns} and optimized 214



Fig. 1. Illustration of a Nano-Spikes Electric Cell Lysis (NSP-ECL) device, (a) the schematic diagram of an NSP-ECL chip with NSP arrays, (b) SEM micrograph of an array of nano-spikes, (c) optical micrograph of an Al foil with fabricated nano-spikes, and (d) optical micrograph of packaged NSP-ECL chip.

electric pulse parameters, NSP-ECL chips offer the advantage of achieving high η_{lysis} at reduced pulse amplitudes and shorter pulse durations. ECL with low pulse amplitudes and shorter pulse durations minimized undesirable electrochemical reactions such as gas and bubble generation and avoided complete disruption and micronization of cell membrane which is desirable in downstream process integration on LOC system. 221

A. Nano-Spikes Based Electric Cell Lysis Chip Design

3D periodic NSP arrays on a microchip were fabricated 223 through electrochemical anodization and etching processes. 3D 224 NSPs were fabricated with different controllable dimensions, 225 such as length, L_{ns} , base radius, R_{ns} , and pitch, P_{ns} (spike to 226 spike distance). The top and bottom electrodes are insulated 227 by a spacer (3M Orange Polyimide electrical insulation tape) 228 with a thickness $d (= 100 \mu m)$. The distance between the tip 229 of the NSPs and the counter electrode of the NSP-ECL chip 230 is defined as $D (= d - L_{ns})$. This spacer not only insulated 231 two electrodes, but also formed a micro-well between two 232 electrodes for cell sample and molecules injection (Fig. 1(a)). 233 The incorporation of optimized aspect-ratio λ NSPs resulted 234 in enhancement of applied electric field. The electric field 235 at NSPs E_{ns} was enhanced by enhancement factor α which 236 depends on the aspect ratio of NSPs. The top electrode of 237 NSP-ECL chip is removable, and cell lysate can be collected 238 from micro-well after electric cell lysis using a pipette. 239

B. 3D Nano-Spikes Fabrication Process

Major steps involved in the fabrication of NSP-ECL ²⁴¹ chips were nano-imprinting and scalable electrochemical ²⁴² anodization and etching processes [31], [51]–[54], [59]. First ²⁴³ of all, low-cost commercially available *ca* 250 μ m thick ²⁴⁴

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Fig. 2. Key fabrication processes of low-cost highly-ordered 3D nano-spike arrays using electrochemical anodization and etching processes, (a) Al foil was imprinted by a silicon mold with squarely patterned pillars, (b) imprinted Al foil with periodic nanoholes, (c) imprinted substrate was anodized and then etched to fabricate 3D nano-spike arrays, and (d) 3D high aspect-ratio nano-spike arrays fabricated through electrochemical anodization and etching processes.

Al foils (99.99% Alfa Aesar, MA, USA) were cut into pieces 245 of 2×1 cm². These Al substrates were cleaned with acetone 246 and then rinsed with isopropyl alcohol and deionized (DI) 247 water. These cleaned substrates were electrochemically pol-248 ished for 4 minutes at 5°C in a 1:3 (v:v) mixture of perchloric 249 acid and ethanol. A silicon stamp with squarely patterned pil-250 lars with a height of ~ 200 nm, the diameter of $\sim 200-500$ nm 251 and pitch of 1.2 μ m was used for nano-imprinting (Fig. 2(a)). 252 The electropolished substrates were imprinted by the stamp 253 and substrates had perfect squarely ordered nano-indentation 254 which defined the location of the anodic alumina mem-255 brane (AAM) pores (Fig. 2(b)). The imprinted substrates were 256 then anodized in a home-built anodization setup using carbon 257 rod as counter electrode using DC voltage of 600 V. The 258 composition of electrolyte used for anodization was 1:1 (v:v) 259 2wt% Citric acid: Ethylene Glycol + 9 mL 0.1wt% Phosphoric 260 acid. NSPs with different aspect ratios were fabricated by 261 controlling anodization conditions, i.e.; anodization time varies 262 between 30-360 minutes at 10°C. Stability of electrolyte was 263 improved by mixing citric acid with ethylene glycol, and the 264 anodization voltage was increased up to 600 V [51]-[54]. The 265 mixture of phosphoric acid (6%) and chromic acid (1.5%) was 266 used to etch the anodized AAM layer at 100°C for 25 minutes 267 268 to obtain perfectly ordered 3D NSP arrays (Fig. 2(c)). After etching, the 3D Al NSP electrodes were rinsed with DI water 269 and blown dry with compressed air. 270

271 C. Scalability of Nano-Spikes Fabrication Process

The dimensions of NSPs were precisely controlled by controlling the parameters and conditions of EA&E process, i.e., the thickness of AAM, anodization time, etc. NSPs with different lengths L_{ns} ranging from 350-1100 nm was fabricated by increasing anodization time from 30-360 minutes. The maximum achievable L_{ns} was about ~1100 nm after



Fig. 3. SEM micrograph of 3D nano-spike arrays with different lengths L_{ns} of (a) 350 nm, (b) 750 nm, and (c) 1100 nm.



Fig. 4. Highly-ordered 3D nano-spike arrays fabricated on low-cost commercial Aluminum foil with an area of $7mm^2$ and also on a 4-inch glass wafer.

anodization of 360 minutes. SEM images of NSP array elec-278 trodes with L_{ns} of 350, 750, and 1100 nm with pitch P_{ns} 279 of 1.2 μ m are shown in Fig. 3. Several advantages are asso-280 ciated with NSPs fabricated using EA&E processes such as 281 periodicity, self-organization, scalability, reproducibility, and 282 high-aspect-ratio λ . Due to the scalability of above mentioned 283 EA&E fabrication process, it was possible to fabricate NSPs 284 on low-cost Al foils for microchips as well as on 4-inch 285 glass wafers (Fig. 4). The sample in microliter range was 286 processed on 3D NSP-ECL chips, while throughput can be 287 scaled up to handle large cell populations $(10^4 - 10^5)$ on 288 NSP-ECL wafers. This simple, low-cost, scalable, repro-289 ducible and reliable process is highly attractive for low energy 290 and cost-effective portable μ -TAS, LOC and smartphone-291 based systems as well as for high throughput and large 292 population applications. 293

III. MATERIAL AND METHODS

A. Cell Line Preparations

Human cervical cancer (HeLa) cell line was used in the 296 ECL experiments to characterize cell lysis efficiencies η_{lysis} 297 on NSP-ECL chips. HeLa cells were cultured and grown in 298 Eagle's minimal essential medium (EMEM) (CCL-2TM, ATCC, 299 VA, USA), supplemented with 10% fetal bovine serum (FBS) 300 (ATCC, VA, USA) and 1% Streptomycin/Penicillin (GIBCO®, 301 Invitrogen Inc., USA) at 37°C and 5% CO₂. To perform the 302 ECL experiments on the NSP-ECL chips, HeLa cells were 303 re-suspended in the Phosphate buffered saline (PBS). Then, 304 the EMEM medium was sucked, washed twice with PBS 305 and trypsinized by 0.25% trypsin/EDTA (GIBCO®, Invit-306 rogen Inc., USA) for 3-5 minutes at 37 °C. The detached 307 cells were centrifuged at 1,200 rpm at room temperature for 308 3 minutes. The concentration of HeLa cells was adjusted to 309 1×10^5 cells/mL in suspension. 310

B. Dual Acridine Orange/Ethidium Bromide Fluorescent Staining

Cell lysis efficiencies η_{lysis} is defined as the percentage of dead cells after application of a lysing electric field [44].

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Fig. 5. The schematics of the experimental setup to perform the electric cell lysing on the fabricated NSP-ECL chips.

 η_{lysis} can be determined by using dual fluorescent dye stain-315 ing using Acridine Orange and Ethidium Bromide (AO/EB; 316 Sigma, St Louis, MO, USA) which are nuclear staining 317 dyes [60]-[62]. Acridine Orange (AO) is a membrane per-318 meable dye and emits green fluorescence while Ethidium 319 Bromide (EB) is membrane-impermeable dye and emits red 320 fluorescence after entering the cell through compromised 321 membranes. Upon staining cells with dual AO/EB dyes, live 322 cells emit green fluorescence while lysed cells with dam-323 aged membrane emit orange-yellow fluorescence [60]-[62]. 324 To determine η_{lysis} , the cell suspension was injected to the 325 NSP-ECL chips and the electric pulses were applied. False 326 readings from the reversibly electroporated cells were avoided 327 by adding dual AO/EB staining solution to the cell suspension 328 5 minutes after the application of electric pulses on the 329 NSP-ECL chips. Lysed cells exhibited orange-yellow fluo-330 rescence when EB dye bind with DNA/RNA either inside 331 or outside the cell through the ruptured cell membrane. 332 η_{lysis} was calculated by counting cells that appeared orange-333 yellow under fluorescence over the entire cells. 334

335 C. Experimental Setup

A PCI 6110 DAQ card (National Instrument, TX, USA) 336 and a Labview program were used to apply electric pulses 337 with adjustable pulse amplitude (V_a) , pulse duration (t_p) and 338 pulse number (P_n) to the NSP-ECL chip as shown in Fig. 5. 339 The cell's response before and after ECL was observed 340 using an Olympus IX70 inverted fluorescent microscope and 341 a QImaging Retiga 1300C digital CCD camera (Burnaby, 342 B.C., Canada) (Fig. 5). Sets of bright field and fluorescence 343 micrographs were acquired by an image capture card. These 344 digital images were processed to determine the η_{lvsis} as a 345 function of electric pulse parameters on NSP-ECL chips. 346

347 D. Statistical Analysis

At least 100 cells were analyzed to obtain each data point, and each experiment was repeated at least three times. The standard deviation between repeated experiments was shown as error bars.

352 IV. ELECTRIC FIELD ENHANCEMENT

Electric field distribution was simulated to evaluate the electric field enhancement at NSPs. A commercial finite



Fig. 6. Numerical simulation of the electric field distribution between nanospike array electrodes using COMSOL at $V_a = 4V$. The simulation shows local electric field enhancement, especially near the nano-spikes.

element method (FEM) package (COMSOL Multiphysics 4.2, 355 COMSOL Ltd., USA) was used for electric field distribution 356 simulations [63]. The profile of NSPs was extracted with the 357 help of extract profiles tool using the AFM images of NSPs. 358 The extracted coordinates of NSPs were then exported to 359 **COMSOL.** The cell lysis chamber is $ca \ 100 \ \mu m$ high (the 360 distance between the top and bottom electrode). The top 361 electrode and the tip of the spikes on the bottom electrode 362 were separated by a distance D (99 μ m) and the space 363 between the two electrodes was considered as cell suspension 364 medium (Fig. 6). The relative permittivity and conductivity 365 of cell suspension medium were assumed to be 77.4 \pm 5% 366 and 1.7 S/m \pm 10%, respectively [59]. The fixed potential 367 between the electrodes was used as the boundary condition. 368 The fixed potential between the electrodes was applied by 369 selecting 2D stationary electrostatics physics in COMSOL. 370 These simulations demonstrated that applied electric field E_a 371 is enhanced and defined by enhancement factor α which on the 372 other hand highly depend on the aspect ratio λ of NSPs. The 373 enhanced electric field E_{ns} is very large near tips of NSPs and 374 E_{ns} become uniform few nm above 3D NSP arrays as shown 375 in Fig. 6. 376

The enhanced electric field E_{ns} was localized on NSPs due to the optimized aspect ratio λ of NSPs. The enhancement factor α by which the applied electric field E_a is enhanced can be estimated using the following relation [64], [65]:

$$E_{ns} = E_a \times \alpha \times \gamma \tag{1} 381$$

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where E_a is the applied electric field (V_a/D) , α is the 382 enhancement factor and γ is the correction factor to incor-383 porate the electrochemical impedance near the fluid-electrode 384 interface and determined through electrochemical impedance 385 spectroscopy [66], [67]. Based on the geometries of nanostruc-386 tures, several models have been proposed to estimate α [65]. 387 In our case, the α was estimated by considering NSP as 388 a hemi-ellipsoid with length L_{ns} and base radius R_{ns} as 389



Fig. 7. Electric field as a function of applied voltages V_a for micro parallel plate electric cell lysing (μ PPECL) device without nano-spikes and NSP-ECL devices with different α .



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$$\alpha = \xi^3 / [\{\lambda ln(\lambda + \xi)\} - \xi]$$
⁽²⁾

where $\xi = (\lambda^2 - 1)^{1/2}$ and λ is the aspect ratio of NSP 392 (L_{ns}/R_{ns}) . It is evident from (2) that α is a function of 393 λ and α can increase exponentially with increasing λ . λ . 394 As mentioned previously, the aspect ratio λ can be controlled 395 by controlling dimensions of NSPs. We have successfully 396 fabricated NSPs with λ up to 3 using EA&E process. For 397 NSPs with L_{ns} of 1100nm, the R_{ns} was 375nm which leads 398 to the aspect ratio of around 3. For NSPs with λ ranging 399 between 2 and 3, α was estimated between 5.9 and 8.9 using 400 Equation (2). For micron-distant parallel plate electric cell 401 lysis (μ PPECL) devices without NSPs, the electric field 402 E_{planar} can be estimated as the ratio of applied voltage V_a 403 to the distance between parallel plate electrodes $D(E_{planar} =$ 404 V_a/D). Interelectrode distance D of ~99 μ m was considered 405 for both μ PPECL and NSP-ECL devices to compare electric 406 field. Enhanced electric field at NSPs E_{ns} was determined 407 using (1) and (2). The electric field was enhanced at NSP-408 ECL devices by enhancement factor α as compare to μ 409 PPECL devices (Fig. 7). This means that lower voltages are 410 required to achieve a specific electric field on the NSP-ECL 411 devices depending on α as compared to μ PPECL devices. For 412 example, electric field of 2 kV/cm can be achieved at 20 V 413 for μ PPECL device, at ~4 V for NSP- ECL device with α 414 of 5.87, at \sim 3 V for NSP- ECL device with α of 7.55 and at 415 ~2.6 V for the NSP-EP ECL device with α of 8.95 (Fig. 7). 416

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V. RESULTS AND DISCUSSION

When a cell is exposed to an externally applied elec-418 tric field, localized transient microstructural changes and 419 nanopore generation takes place in the cell membrane. These 420 changes and induced nano-pores can either resealed (reversible 421 electroporation) or non-resealed (irreversible electroporation) 422 depending on applied electric pulse parameters V_a , t_P and 423 P_n [34]–[37]. Irreversible electroporation causes rupturing of 424 the cell membrane and cell lysis due to dielectric breakdown 425 of the cell membrane as cell unable to maintain essential 426



Fig. 8. Fluorescence micrographs of Acridine orange and Ethidium bromide dual stained HeLa cells treated on NSP-ECL chips and μ PPECL devices. Viable cells exhibit green fluorescence while lysed cells exhibit orange-red fluorescence due to loss of membrane integrity. (a) HeLa cells undergone electric cell lysis (ECL) on μ PPECL without nano-spikes at pulse amplitude $V_a = 5$ V and pulse duration $t_P = 12$ ms, (b) HeLa cells before ECL on NSP-ECL chips ($\alpha = 8.9$), (c) HeLa cells after ECL on NSP-ECL chips ($\alpha = 8.9$) at $V_a = 2$ V and $t_P = 10$ ms, and (d) HeLa cells after ECL on NSP-ECL chips ($\alpha = 8.9$) at $V_a = 2$ V and $t_P = 12$ ms.

ionic balance across the membrane. ECL occurs only when 427 applied electric pulse parameters V_a , t_P and P_n are well above 428 their critical values [4]. Irreversible nano-pore generation is 429 initiated when an electric field is well above its critical value 430 E_{CL} which in turn determined by pulse amplitude V_a and 431 density and duration of these nanopores depend on t_P and 432 P_n [34]–[37]. It is critical to optimize these electric pulse 433 parameters to achieve high η_{lysis} at low energy consumption 434 to avoid undesirable electrochemical reactions and possible 435 integration with portable devices. In our ECL experiments, 436 we have applied rectangular AC pulses with adjustable V_a 437 of 1–10 V, t_P of 1–12 ms and P_n of 1-10 on NSP-ECL chips 438 with α of 5.87, 7.55 and 8.95. 439

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A. Fluorescence Microscopy

Cell lysis efficiencies were quantified by using dual AO/EB 441 fluorescent staining (Fig. 8). Fluorescence micrographs of cells 442 before ECL on NSP-ECL chips showed no yellow-orange 443 fluorescence as cell membrane was intact and impermeable 444 to EB dye molecules (Fig. 8(b)). After ECL, cell membrane 445 ruptured due to induction of irreversible nanopores on cell 446 membranes by applied electric field. EB molecules entered the 447 cells through compromised membrane and stained the lysed 448 cells. Lysed cells exhibited orange-red fluorescence, while the 449 live cells emitted green fluorescence (Fig. 8(c) & (d)). Almost 450 all cells exhibited orange-red fluorescence when lysed on 451 NSP-ECL chips at 2 V and 12 ms pulses showing high η_{lysis} . 452 Fluorescence micrograph of ECL on μ PPECL devices at 5 V 453 and 12 ms pulses showed almost no orange-red fluorescence 454 showing very low η_{lysis} (Fig. 8(a)). 455

B. Enhancement Factor Effect on Electric Cell Lysis

Cell lysis efficiencies were quantified on NSP-ECL chips 457 with different α and on μ PPECL devices in order to determine 458



Fig. 9. Cell lysis efficiency η_{lysis} as a function of applied pulse amplitude V_a on NSP-ECL chips with different α (5.9, 7.5, 8.9) and the cell lysis efficiency of the μ PPECL device for pulse duration t_P of 10ms.

the effect of α on η_{lysis} as compared to μ PPECL devices 459 without NSPs. From Fig. 9, it is clear that cell lysis on 460 NSP-ECL chips showed higher η_{lysis} as compared to cell lysis 461 on μ PPECL devices at specific V_a due to enhanced electric 462 field E_{ns} on NSPs. At $V_a = 3$ V, the η_{lysis} was 40 to 100% 463 high on NSP-ECL chips as compared to μ PPECL devices 464 depending on enhancement factor α of NSP-ECL chips. 465 η_{lysis} was increased with increasing α on NSP-ECL chips at 466 specific V_a . η_{lysis} of 40%, 64% and 100% were achieved at 467 $V_a = 3$ V on NSP-ECL chips with α of 5.87, 7.55 and 8.95 468 respectively. NSP-ECL chips with α of 8.95 was selected for 469 further analysis due to high η_{lysis} at low voltages. 470

471 C. Critical Values for Electric Cell Lysis

Based on the applied electric field, ECL process can be 472 divided into three phases as shown in Fig. 10. When the 473 applied electric field is below critical electric field E_{CL} , η_{lysis} 474 is very low as the electric field is not sufficient to induce 475 enough irreversible nano-pores rather reversible nanopores on 476 the cell membrane. When the applied electric field was above 477 E_{CL} , the electric field was strong enough to break down the 478 integrity of cell membrane by inducing enough irreversible 479 nano-pores. EB fluorescent molecules bound to DNA/RNA 480 inside or outside the ruptured cell membrane and lysed cells 481 exhibited orange-red fluorescence (Fig. 8(c) and (d)). At this 482 stage, a small increase in pulse amplitude V_a , more and more 483 cells lysed and η_{lysis} increased quickly (Fig. 10). η_{lysis} keep on 484 increasing by increasing electric field until η_{lysis} saturated and 485 electric field at this point defined as saturation electric field 486 E_{sat} (Fig. 10). Further increase in V_a did not improve η_{lysis} 487 but increased power consumption. 488

489 D. Electric Pulse Parameters Effects on Electric Cell Lysis

The cell lysis efficiencies were greatly influenced by applied 490 electric pulse parameters such as V_a , t_P and P_n . Higher η_{lvsis} 491 can be achieved at higher pulse amplitude V_a , longer pulse 492 duration t_p and higher pulse number P_n (Fig. 10). Higher pulse 493 amplitude V_a and longer pulse duration t_p increased power 494 requirement and may also induce undesirable electrochemical 495 reactions. Electric pulse parameters should be optimized to 496 achieve high η_{lvsis} but at lower V_a and shorter t_p to minimize 497



Fig. 10. Cell lysis efficiency η_{lysis} as a function of V_a and t_P for P_n of 10 on NSP-ECL chip.

electrochemical reactions and power requirement. We have reached high η_{lysis} (~100%) at V_a of 2 V, t_p of 12 ms and P_n of 10 on NSP-ECL chip (Fig. 10). This reduction in V_a is more than ten times lower as compared to μ PPECL devices.

E. Energy Requirement for Electric Cell Lysis

The energy consumption for electric cell lysis is a crucial 504 issue especially in LOC, μ -TAS and smartphone based 505 microsystems where limited energy is available [3], [68]. This 506 energy requirement is high enough to employ complex, bulky 507 and costly power generators and equipment [16], [69]. Due to 508 high energy requirement, ECL systems usually undergo metal 509 ion dissolution, local pH variation, Joule heating, gas and 510 bubble generation and sample contamination [3], [4], [5], [17], 511 [25], [68], [70]. In order to avoid these undesirable reactions 512 on ECL devices and to integrate them on LOC, μ -TAS 513 and smartphone based microsystems; low energy consumption 514 ECL systems are highly desirable. In our approach, we utilized 515 3D nano-spikes on which electric field was enhanced due to 516 their optimized aspect-ratio. We were able to achieve cell lysis 517 at lower pulse amplitudes due to electric field enhancement. 518 The specific energy input W delivered to samples on NSP-519 ECL chips was calculated using relation: 520

$$W = V_a I P_{n.} t_p / vol \tag{3}$$

where V_a is the applied pulse amplitude, I is the electric 522 current, P_n is the pulse number, t_p is the pulse duration, and 523 vol is the sample volume (0.25 mL). A high-precision $1k\Omega$ 524 resistor was connected in series with the chip and serve as 525 the current-to-voltage converter. The resistance of the resistor 526 is too small as compared to the chip. Therefore, it can 527 be ignored in the electric current calculation. The voltage 528 signals from this resistor were measured by using a PCI 6110 529 DAQ card (National Instrument, TX, USA) and a Labview 530 program and used in the electric current calculation. The 531 specific energy input W required to achieve optimized electric 532 pulse protocol (2V \times 12ms for 10 pulses) was 0.5 mJ/mL 533 (Fig. 11). The energy consumption for cell lysis on NSP-ECL 534



Fig. 11. η_{lysis} for different NSP-ECL and μ PPECL devices as a function of different electric pulse protocols and specific energy input W (mJ/mL).

TABLE III Specific Energy Requirement for Cell Lysis Using Different Methods

Ref.	Methods	Device characteristics	Treatment time	Specific energy input
[72]	Laser	Beam dia. of 100µm	60sec × 10 times	16kJ/mL
[72]	Microwave	1025W 2.45GHz	20min.	74.6kJ/mL
[72]	Mechanical solid shear	Blade dia. 40mm 120W, 3000 rpm	6min.	540kJ/mL
[72]	Thermal lysis	$90^{\circ}C$	20min.	20.1 kJ/mL
[72]	Liquid shear ultrasonication	40W ultrasonic bath	20min.	132 kJ/mL
[73]	High voltage pulsed electric field	$L \times W = 30 \times 3 \text{mm}^2$ $d = 10 \text{mm}$	1µs	100-200 J/mL
[74]	Floatronoration	$A=0.78 \text{ cm}^2$ $d=0.3 \text{ cm}$	µs-ms	16-150 J/mL
[75]	Electroporation	$L \times W:2.8 \times 0.6 \text{ cm}^2$ $d = 1 \text{ mm}$	100µs × 32	5-533 J/mL
This pape r	NSP-ECL device	NSP dimensions L: 350-1100nm D: 200-500nm	12ms × 10	0.05-3 mJ/mL

 $L \times W$: electrode length \times width, *a*: interelectrode distance, *A*: electrode area, *L* diameter

535	chips was 0.5-2 mJ/mL	that	t is 3-9 orders	of magnit	tude lower
536	as compared to other	cell	disintegration	methods	as shown
537	in Table 3.				

Low device reliability and failure were observed in macro 538 and micro ECL devices due to high voltage operations which 539 resulted in electrolysis, gas bubble generation, Joule heating, 540 local pH variations, etc. [21]-[27]. Electrode degradation and 541 cell damage were observed during electroporation and ECL 542 processes due to gas bubbles generation which resulted in local 543 pH variations and violent hydrodynamic forces [21]-[24], 544 [59]. Gas bubble generation was observed on micro devices 545 due to high voltage operation especially above 6 V [22], [75] 546 as shown in Fig. 12(b). Although AC pulses were applied 547 on micro devices which were known to minimize electro-548 chemical reactions, still applied pulse amplitudes were high 549







Fig. 12. Cell morphologies after electric cell lysis on (a) NSP-ECL chips, bubble generation, and cell micronization was avoided and (b) on a micro ECL chip, Bubble generation was observed on micro devices [22], [75].

enough to induce gas bubble generation and electrode degra-550 dation (Fig. 12 (b)). On the other hand, on NSP-ECL chips, 551 due to the employment of NSPs, high η_{lvsis} was achieved at 552 low pulse amplitudes without bubble generation (Fig. 12(a)). 553 In addition, the cell membrane was not fully disintegrated 554 after ECL on NSP-ECL chips (Fig. 12(a)). This will avoid 555 micronization of cell debris and complex, costly and time-556 consuming downstream processes. 557

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F. Phase Diagram for Electric Cell Lysis

ECL occurs successfully when applied electric field is well 559 above its critical value E_{CL} . It is crucial to determine electric 560 pulse parameters to achieve E_{CL} as if the electric field is 561 below this critical value; cells will be reversibly electroporated 562 instead of lysed. E_{CL} was achieved at different V_a for different 563 t_p , at lower V_a for longer t_p , and at higher V_a for shorter t_p . 564 E_{CL} is defined as a critical electric field for cell lysis which 565 induces irreversible nanopores on the cell membrane and η_{lysis} 566 increases quickly. We have also determined electric pulse 567 parameters to achieve saturation electric field E_{sat} at which 568 η_{lysis} saturated. It is vital to determine E_{sat} as increasing 569 pulse parameters after this point will only result in additional 570 power hence energy consumption and micronization of cell 571 debris which is not suitable for portable LOC systems and 572 downstream processes. Using these parameters for E_{CL} and 573 E_{sat} , we have constructed "phase diagram" for ECL of HeLa 574 cells on NSP-ECL chips (Fig. 13). Phase diagram defines 575



Fig. 13. The Phase diagram for the electric cell lysis of HeLa cells on the NSP-ECL chip ($\alpha = 8.9$). The Phase diagram shows the non-ECL and ECL regions for different applied pulse durations.

the boundary for non-ECL and ECL regions for different electric pulse parameters. Minimum pulse amplitude $V_{CL,min}$ to achieve E_{CL} was 0.9 V for t_p of 12 ms which is more than thirteen times lower as compared to μ PPECL devices. Minimum pulse amplitude $V_{sat,min}$ to achieve E_{sat} was 2 V for t_p of 12 ms which is more than ten times lower as compared to μ PPECL devices.

VI. CONCLUSION

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In conclusion, we have developed a low-cost energy-584 efficient 3D nano-spike based electric cell lysis (NSP-ECL) 585 chips for efficient cell lysis at low pulse amplitudes and 586 duration. Highly-ordered self-aligned 3D Al NSP arrays with 587 controllable dimensions, i.e., length, L_{ns} , base radius, R_{ns} , 588 and pitch, P_{ns} (spike to spike distance) were fabricated 589 on low-cost commercial Al foils through simple, scalable, 590 reproducible and cost effective electrochemical anodization 591 and etching processes. The electric field has been localized 592 at NSPs due to optimized aspect-ratio with an enhancement 593 factor α as compared to micro-distant parallel plate electric 594 cell lysis (μ PPECL) chips without NSPs. NSP-ECL chips 595 have achieved high cell lysis efficiencies η_{lysis} (100%) at 596 more than ten times reduced pulse amplitudes (2 V) through 597 localized electric field E_{ns} as compared to the μ PPECL 598 chips without NSPs. These applied pulse amplitudes are 599 2-3 times reduced as compared to traditional electropora-600 tion systems used for different applications. The specific 601 energy input required to achieve 100% η_{lysis} was only in 602 the range of 0.5-2 mJ/mL which is 3-9 orders of magni-603 tude lower as compared to other cell disintegration methods 604 (5J/mL-540kJ/mL). The employment of NSPs fabricated 605 through low-cost EA&E process, optimized AC electric pulses 606 with low amplitudes and short durations minimized undesir-607 able electrochemical reactions, such as gas and bubble genera-608 tion on NSP-ECL chips which were observed on micro devices 609 due to high voltage operation. Due to the scalability of the 610 fabrication process, 3D NSPs were fabricated on small chips as 611 well as on wafers to process samples for microsystems as well 612 as for high throughput applications. These energy-efficient 613 NSP-ECL chips are highly attractive for integration with 614 other sample preparation downstream processes on portable 615 LOC and μ -TAS systems due to its low power consumption, 616

reliability, cost-effectiveness and avoiding micronization of cell debris. Based on these low voltage devices, we can add additional ECL tool in a recently developed "Lab on Smartphone" through which optimized EP protocols can be applied to micro/nano EP chips through an open-source MCU (Arduino) with an integrated Bluetooth module [48].

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Low-Cost Energy-Efficient 3-D Nano-Spikes-Based Electric Cell Lysis Chips

Kashif Riaz, Siu-Fung Leung, Zhiyong Fan, Member, IEEE, and Yi-Kuen Lee, Member, IEEE

Abstract—Electric cell lysis (ECL) is a promising technique to be integrated with portable lab-on-a-chip without lysing 2 agent due to its simplicity and fast processing. ECL is usually 3 limited by the requirements of high power/voltage and costly 4 fabrication. In this paper, we present low-cost 3-D nano-spikes-5 based ECL (NSP-ECL) chips for efficient cell lysis at low power 6 consumption. Highly ordered HAR NSP arrays with control-7 8 lable dimensions were fabricated on commercial aluminum foils through scalable and electrochemical anodization and etching. 9 The optimized multiple pulse protocols with minimized unde-10 sirable electrochemical reactions (gas and bubble generation), 11 common on micro parallel-plate ECL chips. Due to the scalability 12 of fabrication process, 3-D NSPs were fabricated on small chips 13 as well as on 4-in wafers. Phase diagram was constructed by 14 defining critical electric field to induce cell lysis and for cell lysis 15 saturation E_{sat} to define non-ECL and ECL regions for different 16 pulse parameters. NSP-ECL chips have achieved excellent cell 17 lysis efficiencies η_{lysis} (ca 100%) at low applied voltages (2 V), 18 2~3 orders of magnitude lower than that of conventional systems. 19 The energy consumption of NSP-ECL chips was 0.5-2 mJ/mL, 20 21 $3\sim9$ orders of magnitude lower as compared with the other methods (5J/mL-540kJ/mL). [2016-0305] 22

Index Terms—Nano-spikes, electric cell lysis chips, elec trochemical anodization and etching processes, electric field
 enhancement, energy-efficient, lab on chip.

I. INTRODUCTION

CELL LYSIS is an important step in sample preparation procedures and biopharmaceutical product extraction to release intracellular contents, i.e., DNA, RNA, hormones, vaccines, antibodies, recombinant proteins, and so forth. by disrupting cell membrane [1]–[6]. Economics of these procedures is greatly influenced by downstream processing steps, i.e., separation, purification, and so on. [1]. Sample preparation for molecular, protein and genomic diagnostic and analysis is time-consuming, labor intensive and costly process due

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to multiple steps and bulky instruments [4], [6]-[8]. Lab-36 on-a-chip (LOC) and micro total analysis system (μ -TAS) 37 are rapidly growing in different fields ranging from mole-38 cular/protein/genome diagnostic and analysis to the search 39 for life on Mars [9]-[13]. Due to recent developments in 40 micro/nanotechnologies, conventional bulky and costly sample 41 preparation processes can be scaled down and integrated into a 42 single compact, automated, and portable microsystem, LOC or 43 μ -TAS [4]–[12]. These microsystems have great promise due 44 to their simplicity, low cost, time efficiency, low consumption 45 of valuable reagents and biological samples [4]-[12]. 46

Numerous techniques have been employed for cell lysis on 47 integrated microsystems, LOC, or μ -TAS such as mechanical, 48 chemical, thermal, ultrasonic, optical, electrical, with their 49 unique advantages and limitations [2]-[7]. Mechanical cell 50 lysis (MCL) based on exerting localized high pressure, shear 51 stress, friction forces, compressive stress, on cell membrane 52 through micro-channels, filters, moving membranes, beads, 53 etc [2]–[5]. MCL integration on LOC is limited due to moving 54 parts and blockage of micro/nanochannels, gaps, filters by cell 55 debris [3]-[5]. Furthermore, due to cell debris micronization 56 into small fragments and non-selective release of products 57 through MCL; additional costly and time-consuming sepa-58 ration and purification steps are required [3]-[5]. Chemical 59 cell lysis (CCL) utilized lysis agents such as surfactants, 60 enzymes, detergents, etc., to dissolve cell membrane in 61 microfluidic channel network [2]-[5]. CCL methods are lim-62 ited due to pretreatment of lysing agents, purification of the 63 added agents for downstream processing, different protocols 64 for different samples and inherently slow due to complex 65 chemical processes [3]–[5]. Thermal cell lysis utilized high 66 temperatures and cyclic heating for cell lysis but not suitable 67 for portable LOC systems due to high power requirement for 68 heat generation and irreversible protein denaturation [3]-[5]. 69 Ultrasonic cell lysis is not suitable for LOC systems due 70 to complex instrumentation, excessive heat generation, and 71 inefficient power transmission to samples [2]-[5]. Intracellular 72 product yield greatly improved by increasing the intensity 73 of cell lysis methods mentioned above, but it also increases 74 micronization of cell debris and additional contaminants from 75 intracellular compartments [1]. This increases the produc-76 tion cost and processing time due to additional downstream 77 processing, i.e., separation, purification, etc. [1]. 78

Electric Cell lysis (ECL) is a physical method that has potential to overcome these limitations due to its simplicity, cost effectiveness, high efficiency, fast processing, easy miniaturization, applicability to diverse samples, and possible

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TABLE I Comparison of Micro/Nano Electric Cell Lysis Chips

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Ref.	Electrode	Amplitude (V)	Duration	Efficiency (%)	Remarks
[39]	3D Au/Ti micro	~8.5	-	74	Low efficiency
[40]	Pt/Ti micro	10-40	-	<80	Bubble generation
[18]	3D Au/Cr micro	10	-	30	Low efficiency
[38]	MWCNT	40	-	~100	High voltage
[14]	Cr/Au micro	20	100 µs	90	High voltage
[41]	Cr/Au micro	10	-	80	Low efficiency
[42]	Cr/Au micro	10	-	80	Low efficiency
[43]	ITO micro	30	-	61	Low efficiency
[44]	Cr/Au micro	5-6	5-10 min.	>95	Longer time
[45]	3D carbon micro	130	400 ms	90	High voltage
[46]	Pt/Ta micro	20	0.5-2 s	~100	High voltage
Our work	3D Nano spikes	2	12ms	100±0.1	Low voltage High efficiency

integration with downstream processes as no lysis agents 83 required [2]–[6], [14]. ECL employs intense pulsed elec-84 tric field to induce irreversible nanopores on cell membrane 85 which leads to cell lysis [2], [3]. ECL has been proved 86 effective in avoiding complete cell disruption, micronization 87 of cell debris and contaminants from intracellular compart-88 ments by selectively lysing the cell membrane rapidly and 89 quickly [15]. Besides these advantages, ECL methods are 90 limited by high energy consumption (5-500 J/mL) and voltage 91 requirement (few tens of volts) as listed in Table 1 to achieve 92 critical electric field for cell lysis E_{CL} (kV/cm). To fulfill 93 these requirements, special costly and bulky power generators 94 are necessary. This is highly undesirable in portable LOC 95 applications [3], [4], [16]. Various designs have been proposed 96 to achieve E_{CL} at low voltages either by decreasing the 97 distance between electrodes or focusing electric field through 98 small constriction segments and structures in microchan-99 nels or micro-chambers [2]-[4], [17]. Most commonly used 100 2D planar electrodes suffer from uneven exposure of cells 101 to an electric field, resulting in low cell lysis efficiencies 102 η_{lysis} [3], [16]. 3D electrodes were designed to overcome this 103 drawback which showed higher η_{lysis} (30%) as compared to 104 2D electrodes (8%) [18]. However, the fabrication of 3D elec-105 trodes usually involves complex, time-consuming and costly 106 fabrication steps [19], [20]. 107

Direct current (DC) voltage is preferred as cell membrane experienced larger transmembrane potential (TMP) without lysing the intracellular components [3], [4], [17]. However, the voltage required to achieve electric field in kV/cm range usually lead to water electrolysis which may lead to gas bubble generation, extreme pH conditions and Joule

TABLE II Comparison of Electric Cell Lysis on Electrodes With and Without Nanostructures

Ref.	Nano-structures	Voltage requirement (V)	Without nano-structures (V)	Efficiency (%)
[38]	MWCNTs	40	85	100
[35]	CNTS	35	135	>95
[36]	CNTs	35	135	>95
[37]	CNTs	40	>90	100
[34]	Nano-gaped ITO electrodes	9	-	~90
this paper	3D Nano-spikes	2	>10	100±0.1

heating [3], [21]. Alternating current (AC) voltages have 114 been used to minimize these problems for on-chip ECL at 115 optimized frequencies [3], [4], [21]. Depending on applied 116 electric pulse amplitude, duration and number (usually high 117 for ECL), AC ECL techniques also suffer from gas bubble 118 generation, Joule heating, and pH variations [21]-[24]. These 119 undesirable phenomena resulted in the production of unwanted 120 electrolytic chemical compounds led to electrode degradation, 121 effects on thermo-sensitive intracellular contents, i.e., proteins 122 and on reaction kinetics of specific application [25]-[27]. 123 To avoid these drawbacks, subcellular sized constriction 124 structures were employed in a microchannel, so that maxi-125 mum potential drop was across the cell membrane trapped 126 in these structures instead of in the vicinity of the elec-127 trodes [28], [29]. The integration of these structures on 128 portable LOC is limited by complex and costly manufactur-129 ing steps, expensive equipment for micro/nanoflow, channel 130 blocking by cell debris and bubbles [3], [17], [25]-[27]. The 131 average electric current between the electrodes can also be 132 reduced by applying AC pulses with low amplitude and shorter 133 duration. However, pulse parameters should be optimized to 134 achieve high η_{lysis} in addition to the minimization of unde-135 sirable electrochemical reactions [21], [25], [30], [31]. Cell 136 lysis efficiencies were always a concern in previous reports 137 and η_{lvsis} were well below 100% in most of the methods 138 mentioned above [2], [3], [4] (Table 1). 139

High-aspect-ratio nano-structures (nano-tubes, nano-wires 140 etc.) were incorporated on electrodes to locally enhance 141 electric field intensity to cell membranes and used for cell 142 lysis [32]-[37]. The cell lysing results on these chips indi-143 cated that required voltage reduced as compared to electrodes 144 without nano-structures but still in the range of few tens 145 of volts [32]–[37] (Table 2). One of the bottlenecks in the 146 integration of nanostructures on microchips are the difficulties 147 in handling, aligning and positioning the nanostructures at 148 the exact desired location [46]. Furthermore, the fabrication 149 techniques employed are complex, costly, time-consuming and 150 non-reproducible [46]. It is highly desirable to establish sim-151 ple, inexpensive, reliable and scalable fabrication techniques 152 for fabrication of reproducible and aligned nanostructures to 153 be used in integrated portable LOC systems and potential mass 154 production [9], [46]-[48]. 155

In this work, we present a low-cost 3D nano-spike based 156 electric cell lysis chip which employed self-aligned highly 157

ordered 3D Aluminum (Al) nano-spike (NSP) arrays fabricated 158 through electrochemical anodization and etching (EA&E) 159 processes using anodic alumina membrane(AAM) as a tem-160 plate. 3D self-aligned highly ordered nano-structures were 161 fabricated using EA&E processes recently due to their sim-162 plicity, low cost, reproducibility, and scalability [49]. These 163 nano-structures showed enhanced performance in the field of 164 electronics, optoelectronic, photovoltaic, magnetism, medical, 165 and biology [49], [51]–[54]. Alumina is already recognized 166 as bio-compatible material and used in hip arthroplasty [55], 167 tissue engineering especially for skin replacement [56], bone 168 implant [57], and cell culture and proliferation [58]. 169

We developed an energy-efficient 3D nano-spikes based 170 electric cell lysis (NSP-ECL) chips for efficient cell lysis 171 at low energy consumption. NSP-ECL chips comprised of 172 highly-ordered high-aspect-ratio (λ) 3D Al NSP arrays with 173 controllable dimensions, i.e., length, L_{ns} , base radius, R_{ns} , 174 and pitch, P_{ns} (spike to spike distance). These optimized 175 aspect-ratio λ (= L_{ns}/R_{ns}) NSPs were fabricated on low-cost 176 commercial Al foils through simple, scalable, reproducible 177 and cost effective EA&E process. The electric field has been 178 localized at NSPs due to high λ with an enhancement factor 179 α . NSP-ECL chips have achieved high cell lysis efficiencies 180 η_{lysis} (100%) at more than ten times reduced pulse ampli-181 tudes (2 V) through localized electric field E_{NSP} as compared 182 to micron-distant parallel plate electric cell lysis (μ PPECL) 183 chips without NSPs. The employment of low-cost EA&E 184 fabrication process, optimized AC electric pulses with low 185 amplitudes (2 V), short durations (few milliseconds) and low 186 energy consumption (0.5-2 mJ/mL) minimized undesirable 187 electrochemical reactions, such as gas and bubble generation 188 on NSP-ECL chips. Due to the scalability of the fabrication 189 process, 3D NSPs were fabricated on small chips as well as 190 on wafers. 191

192 II. NANO-SPIKES BASED ELECTRIC CELL LYSIS SYSTEM

Schematic diagram of a nano-spikes based electric cell 193 lysis (NSP-ECL) system along with optical micrograph 194 of fabricated nano-spikes on an Al foil and packaged 195 NSP-ECL chip is shown Fig. 1. NSP-ECL chips consist 196 of 3D periodic NSP arrays fabricated on a low-cost commer-197 cial Al foil using nano-imprint lithography, electrochemical 198 processes, i.e., anodization and etching and MEMS technol-199 ogy. By controlling dimensions of NSPs, NSPs were fab-200 ricated with different aspect ratios λ (= L_{ns}/R_{ns}). Large 201 λ resulted in electric field enhancement E_{ns} at NSPs and 202 applied electric field E_a was enhanced with an enhancement 203 factor α . A PCI 6110 DAQ card (National Instrument, TX, 204 USA) and a Labview program were used to apply AC electric 205 pulses with adjustable pulse amplitudes V_a , durations t_p and 206 number P_n to NSP-ECL chips. An Olympus IX70 inverted 207 fluorescent microscope, and a QImaging Retiga 1300C digital 208 CCD camera (Burnaby, B.C., Canada) were used to acquire 209 a set of bright field and fluorescent micrographs before and 210 after ECL through an image capture card. Cell lysis efficiency 211 η_{lysis} were determined as functions of electric pulse parame-212 ters $(V_a, t_p \text{ and } P_n)$ and NSPs dimensions using these acquired 213 images through image processing. Due to E_{ns} and optimized 214



Fig. 1. Illustration of a Nano-Spikes Electric Cell Lysis (NSP-ECL) device, (a) the schematic diagram of an NSP-ECL chip with NSP arrays, (b) SEM micrograph of an array of nano-spikes, (c) optical micrograph of an Al foil with fabricated nano-spikes, and (d) optical micrograph of packaged NSP-ECL chip.

electric pulse parameters, NSP-ECL chips offer the advantage of achieving high η_{lysis} at reduced pulse amplitudes and shorter pulse durations. ECL with low pulse amplitudes and shorter pulse durations minimized undesirable electrochemical reactions such as gas and bubble generation and avoided complete disruption and micronization of cell membrane which is desirable in downstream process integration on LOC system. 221

A. Nano-Spikes Based Electric Cell Lysis Chip Design

3D periodic NSP arrays on a microchip were fabricated 223 through electrochemical anodization and etching processes. 3D 224 NSPs were fabricated with different controllable dimensions, 225 such as length, L_{ns} , base radius, R_{ns} , and pitch, P_{ns} (spike to 226 spike distance). The top and bottom electrodes are insulated 227 by a spacer (3M Orange Polyimide electrical insulation tape) 228 with a thickness $d (= 100 \mu m)$. The distance between the tip 229 of the NSPs and the counter electrode of the NSP-ECL chip 230 is defined as $D (= d - L_{ns})$. This spacer not only insulated 231 two electrodes, but also formed a micro-well between two 232 electrodes for cell sample and molecules injection (Fig. 1(a)). 233 The incorporation of optimized aspect-ratio λ NSPs resulted 234 in enhancement of applied electric field. The electric field 235 at NSPs E_{ns} was enhanced by enhancement factor α which 236 depends on the aspect ratio of NSPs. The top electrode of 237 NSP-ECL chip is removable, and cell lysate can be collected 238 from micro-well after electric cell lysis using a pipette. 239

B. 3D Nano-Spikes Fabrication Process

Major steps involved in the fabrication of NSP-ECL ²⁴¹ chips were nano-imprinting and scalable electrochemical ²⁴² anodization and etching processes [31], [51]–[54], [59]. First ²⁴³ of all, low-cost commercially available *ca* 250 μ m thick ²⁴⁴

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Fig. 2. Key fabrication processes of low-cost highly-ordered 3D nano-spike arrays using electrochemical anodization and etching processes, (a) Al foil was imprinted by a silicon mold with squarely patterned pillars, (b) imprinted Al foil with periodic nanoholes, (c) imprinted substrate was anodized and then etched to fabricate 3D nano-spike arrays, and (d) 3D high aspect-ratio nano-spike arrays fabricated through electrochemical anodization and etching processes.

Al foils (99.99% Alfa Aesar, MA, USA) were cut into pieces 245 of 2×1 cm². These Al substrates were cleaned with acetone 246 and then rinsed with isopropyl alcohol and deionized (DI) 247 water. These cleaned substrates were electrochemically pol-248 ished for 4 minutes at 5°C in a 1:3 (v:v) mixture of perchloric 249 acid and ethanol. A silicon stamp with squarely patterned pil-250 lars with a height of ~ 200 nm, the diameter of $\sim 200-500$ nm 251 and pitch of 1.2 μ m was used for nano-imprinting (Fig. 2(a)). 252 The electropolished substrates were imprinted by the stamp 253 and substrates had perfect squarely ordered nano-indentation 254 which defined the location of the anodic alumina mem-255 brane (AAM) pores (Fig. 2(b)). The imprinted substrates were 256 then anodized in a home-built anodization setup using carbon 257 rod as counter electrode using DC voltage of 600 V. The 258 composition of electrolyte used for anodization was 1:1 (v:v) 259 2wt% Citric acid: Ethylene Glycol + 9 mL 0.1wt% Phosphoric 260 acid. NSPs with different aspect ratios were fabricated by 261 controlling anodization conditions, i.e.; anodization time varies 262 between 30-360 minutes at 10°C. Stability of electrolyte was 263 improved by mixing citric acid with ethylene glycol, and the 264 anodization voltage was increased up to 600 V [51]-[54]. The 265 mixture of phosphoric acid (6%) and chromic acid (1.5%) was 266 used to etch the anodized AAM layer at 100°C for 25 minutes 267 268 to obtain perfectly ordered 3D NSP arrays (Fig. 2(c)). After etching, the 3D Al NSP electrodes were rinsed with DI water 269 and blown dry with compressed air. 270

271 C. Scalability of Nano-Spikes Fabrication Process

The dimensions of NSPs were precisely controlled by controlling the parameters and conditions of EA&E process, i.e., the thickness of AAM, anodization time, etc. NSPs with different lengths L_{ns} ranging from 350-1100 nm was fabricated by increasing anodization time from 30-360 minutes. The maximum achievable L_{ns} was about ~1100 nm after



Fig. 3. SEM micrograph of 3D nano-spike arrays with different lengths L_{ns} of (a) 350 nm, (b) 750 nm, and (c) 1100 nm.



Fig. 4. Highly-ordered 3D nano-spike arrays fabricated on low-cost commercial Aluminum foil with an area of 7mm² and also on a 4-inch glass wafer.

anodization of 360 minutes. SEM images of NSP array elec-278 trodes with L_{ns} of 350, 750, and 1100 nm with pitch P_{ns} 279 of 1.2 μ m are shown in Fig. 3. Several advantages are asso-280 ciated with NSPs fabricated using EA&E processes such as 281 periodicity, self-organization, scalability, reproducibility, and 282 high-aspect-ratio λ . Due to the scalability of above mentioned 283 EA&E fabrication process, it was possible to fabricate NSPs 284 on low-cost Al foils for microchips as well as on 4-inch 285 glass wafers (Fig. 4). The sample in microliter range was 286 processed on 3D NSP-ECL chips, while throughput can be 287 scaled up to handle large cell populations $(10^4 - 10^5)$ on 288 NSP-ECL wafers. This simple, low-cost, scalable, repro-289 ducible and reliable process is highly attractive for low energy 290 and cost-effective portable μ -TAS, LOC and smartphone-291 based systems as well as for high throughput and large 292 population applications. 293

III. MATERIAL AND METHODS

A. Cell Line Preparations

Human cervical cancer (HeLa) cell line was used in the 296 ECL experiments to characterize cell lysis efficiencies η_{lysis} 297 on NSP-ECL chips. HeLa cells were cultured and grown in 298 Eagle's minimal essential medium (EMEM) (CCL-2[™], ATCC, 299 VA, USA), supplemented with 10% fetal bovine serum (FBS) 300 (ATCC, VA, USA) and 1% Streptomycin/Penicillin (GIBCO®, 301 Invitrogen Inc., USA) at 37°C and 5% CO₂. To perform the 302 ECL experiments on the NSP-ECL chips, HeLa cells were 303 re-suspended in the Phosphate buffered saline (PBS). Then, 304 the EMEM medium was sucked, washed twice with PBS 305 and trypsinized by 0.25% trypsin/EDTA (GIBCO®, Invit-306 rogen Inc., USA) for 3-5 minutes at 37 °C. The detached 307 cells were centrifuged at 1,200 rpm at room temperature for 308 3 minutes. The concentration of HeLa cells was adjusted to 309 1×10^5 cells/mL in suspension. 310

B. Dual Acridine Orange/Ethidium Bromide Fluorescent Staining

Cell lysis efficiencies η_{lysis} is defined as the percentage of dead cells after application of a lysing electric field [44].

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Fig. 5. The schematics of the experimental setup to perform the electric cell lysing on the fabricated NSP-ECL chips.

 η_{lysis} can be determined by using dual fluorescent dye stain-315 ing using Acridine Orange and Ethidium Bromide (AO/EB; 316 Sigma, St Louis, MO, USA) which are nuclear staining 317 dyes [60]-[62]. Acridine Orange (AO) is a membrane per-318 meable dye and emits green fluorescence while Ethidium 319 Bromide (EB) is membrane-impermeable dye and emits red 320 fluorescence after entering the cell through compromised 321 membranes. Upon staining cells with dual AO/EB dyes, live 322 cells emit green fluorescence while lysed cells with dam-323 aged membrane emit orange-yellow fluorescence [60]-[62]. 324 To determine η_{lysis} , the cell suspension was injected to the 325 NSP-ECL chips and the electric pulses were applied. False 326 readings from the reversibly electroporated cells were avoided 327 by adding dual AO/EB staining solution to the cell suspension 328 5 minutes after the application of electric pulses on the 329 NSP-ECL chips. Lysed cells exhibited orange-yellow fluo-330 rescence when EB dye bind with DNA/RNA either inside 331 or outside the cell through the ruptured cell membrane. 332 η_{lysis} was calculated by counting cells that appeared orange-333 yellow under fluorescence over the entire cells. 334

335 C. Experimental Setup

A PCI 6110 DAQ card (National Instrument, TX, USA) 336 and a Labview program were used to apply electric pulses 337 with adjustable pulse amplitude (V_a) , pulse duration (t_p) and 338 pulse number (P_n) to the NSP-ECL chip as shown in Fig. 5. 339 The cell's response before and after ECL was observed 340 using an Olympus IX70 inverted fluorescent microscope and 341 a QImaging Retiga 1300C digital CCD camera (Burnaby, 342 B.C., Canada) (Fig. 5). Sets of bright field and fluorescence 343 micrographs were acquired by an image capture card. These 344 digital images were processed to determine the η_{lysis} as a 345 function of electric pulse parameters on NSP-ECL chips. 346

347 D. Statistical Analysis

At least 100 cells were analyzed to obtain each data point, and each experiment was repeated at least three times. The standard deviation between repeated experiments was shown as error bars.

352 IV. ELECTRIC FIELD ENHANCEMENT

Electric field distribution was simulated to evaluate the electric field enhancement at NSPs. A commercial finite



Fig. 6. Numerical simulation of the electric field distribution between nanospike array electrodes using COMSOL at $V_a = 4V$. The simulation shows local electric field enhancement, especially near the nano-spikes.

element method (FEM) package (COMSOL Multiphysics 4.2, 355 COMSOL Ltd., USA) was used for electric field distribution 356 simulations [63]. The profile of NSPs was extracted with the 357 help of extract profiles tool using the AFM images of NSPs. 358 The extracted coordinates of NSPs were then exported to 359 **COMSOL.** The cell lysis chamber is $ca \ 100 \ \mu m$ high (the 360 distance between the top and bottom electrode). The top 361 electrode and the tip of the spikes on the bottom electrode 362 were separated by a distance D (99 μ m) and the space 363 between the two electrodes was considered as cell suspension 364 medium (Fig. 6). The relative permittivity and conductivity 365 of cell suspension medium were assumed to be 77.4 \pm 5% 366 and 1.7 S/m \pm 10%, respectively [59]. The fixed potential 367 between the electrodes was used as the boundary condition. 368 The fixed potential between the electrodes was applied by 369 selecting 2D stationary electrostatics physics in COMSOL. 370 These simulations demonstrated that applied electric field E_a 371 is enhanced and defined by enhancement factor α which on the 372 other hand highly depend on the aspect ratio λ of NSPs. The 373 enhanced electric field E_{ns} is very large near tips of NSPs and 374 E_{ns} become uniform few nm above 3D NSP arrays as shown 375 in Fig. 6. 376

The enhanced electric field E_{ns} was localized on NSPs due to the optimized aspect ratio λ of NSPs. The enhancement factor α by which the applied electric field E_a is enhanced can be estimated using the following relation [64], [65]:

$$E_{ns} = E_a \times \alpha \times \gamma \tag{1} 381$$

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where E_a is the applied electric field (V_a/D) , α is the 382 enhancement factor and γ is the correction factor to incor-383 porate the electrochemical impedance near the fluid-electrode 384 interface and determined through electrochemical impedance 385 spectroscopy [66], [67]. Based on the geometries of nanostruc-386 tures, several models have been proposed to estimate α [65]. 387 In our case, the α was estimated by considering NSP as 388 a hemi-ellipsoid with length L_{ns} and base radius R_{ns} as 389



Fig. 7. Electric field as a function of applied voltages V_a for micro parallel plate electric cell lysing (μ PPECL) device without nano-spikes and NSP-ECL devices with different α .



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$$\alpha = \xi^3 / [\{\lambda ln(\lambda + \xi)\} - \xi]$$
⁽²⁾

where $\xi = (\lambda^2 - 1)^{1/2}$ and λ is the aspect ratio of NSP 392 (L_{ns}/R_{ns}) . It is evident from (2) that α is a function of 393 λ and α can increase exponentially with increasing λ . λ . 394 As mentioned previously, the aspect ratio λ can be controlled 395 by controlling dimensions of NSPs. We have successfully 396 fabricated NSPs with λ up to 3 using EA&E process. For 397 NSPs with L_{ns} of 1100nm, the R_{ns} was 375nm which leads 398 to the aspect ratio of around 3. For NSPs with λ ranging 399 between 2 and 3, α was estimated between 5.9 and 8.9 using 400 Equation (2). For micron-distant parallel plate electric cell 401 lysis (μ PPECL) devices without NSPs, the electric field 402 E_{planar} can be estimated as the ratio of applied voltage V_a 403 to the distance between parallel plate electrodes $D(E_{planar} =$ 404 V_a/D). Interelectrode distance D of ~99 μ m was considered 405 for both μ PPECL and NSP-ECL devices to compare electric 406 field. Enhanced electric field at NSPs E_{ns} was determined 407 using (1) and (2). The electric field was enhanced at NSP-408 ECL devices by enhancement factor α as compare to μ 409 PPECL devices (Fig. 7). This means that lower voltages are 410 required to achieve a specific electric field on the NSP-ECL 411 devices depending on α as compared to μ PPECL devices. For 412 example, electric field of 2 kV/cm can be achieved at 20 V 413 for μ PPECL device, at ~4 V for NSP- ECL device with α 414 of 5.87, at \sim 3 V for NSP- ECL device with α of 7.55 and at 415 ~2.6 V for the NSP-EP ECL device with α of 8.95 (Fig. 7). 416

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V. RESULTS AND DISCUSSION

When a cell is exposed to an externally applied elec-418 tric field, localized transient microstructural changes and 419 nanopore generation takes place in the cell membrane. These 420 changes and induced nano-pores can either resealed (reversible 421 electroporation) or non-resealed (irreversible electroporation) 422 depending on applied electric pulse parameters V_a , t_P and 423 P_n [34]–[37]. Irreversible electroporation causes rupturing of 424 the cell membrane and cell lysis due to dielectric breakdown 425 of the cell membrane as cell unable to maintain essential 426



Fig. 8. Fluorescence micrographs of Acridine orange and Ethidium bromide dual stained HeLa cells treated on NSP-ECL chips and μ PPECL devices. Viable cells exhibit green fluorescence while lysed cells exhibit orange-red fluorescence due to loss of membrane integrity. (a) HeLa cells undergone electric cell lysis (ECL) on μ PPECL without nano-spikes at pulse amplitude $V_a = 5$ V and pulse duration $t_P = 12$ ms, (b) HeLa cells before ECL on NSP-ECL chips ($\alpha = 8.9$), (c) HeLa cells after ECL on NSP-ECL chips ($\alpha = 8.9$) at $V_a = 2$ V and $t_P = 10$ ms, and (d) HeLa cells after ECL on NSP-ECL chips ($\alpha = 8.9$) at $V_a = 2$ V and $t_P = 12$ ms.

ionic balance across the membrane. ECL occurs only when 427 applied electric pulse parameters V_a , t_P and P_n are well above 428 their critical values [4]. Irreversible nano-pore generation is 429 initiated when an electric field is well above its critical value 430 E_{CL} which in turn determined by pulse amplitude V_a and 431 density and duration of these nanopores depend on t_P and 432 P_n [34]–[37]. It is critical to optimize these electric pulse 433 parameters to achieve high η_{lysis} at low energy consumption 434 to avoid undesirable electrochemical reactions and possible 435 integration with portable devices. In our ECL experiments, 436 we have applied rectangular AC pulses with adjustable V_a 437 of 1–10 V, t_P of 1–12 ms and P_n of 1-10 on NSP-ECL chips 438 with α of 5.87, 7.55 and 8.95.

A. Fluorescence Microscopy

Cell lysis efficiencies were quantified by using dual AO/EB 441 fluorescent staining (Fig. 8). Fluorescence micrographs of cells 442 before ECL on NSP-ECL chips showed no yellow-orange 443 fluorescence as cell membrane was intact and impermeable 444 to EB dye molecules (Fig. 8(b)). After ECL, cell membrane 445 ruptured due to induction of irreversible nanopores on cell 446 membranes by applied electric field. EB molecules entered the 447 cells through compromised membrane and stained the lysed 448 cells. Lysed cells exhibited orange-red fluorescence, while the 449 live cells emitted green fluorescence (Fig. 8(c) & (d)). Almost 450 all cells exhibited orange-red fluorescence when lysed on 451 NSP-ECL chips at 2 V and 12 ms pulses showing high η_{lvsis} . 452 Fluorescence micrograph of ECL on μ PPECL devices at 5 V 453 and 12 ms pulses showed almost no orange-red fluorescence 454 showing very low η_{lysis} (Fig. 8(a)). 455

B. Enhancement Factor Effect on Electric Cell Lysis

Cell lysis efficiencies were quantified on NSP-ECL chips 457 with different α and on μ PPECL devices in order to determine 458

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Fig. 9. Cell lysis efficiency η_{lysis} as a function of applied pulse amplitude V_a on NSP-ECL chips with different α (5.9, 7.5, 8.9) and the cell lysis efficiency of the μ PPECL device for pulse duration t_P of 10ms.

the effect of α on η_{lysis} as compared to μ PPECL devices 459 without NSPs. From Fig. 9, it is clear that cell lysis on 460 NSP-ECL chips showed higher η_{lysis} as compared to cell lysis 461 on μ PPECL devices at specific V_a due to enhanced electric 462 field E_{ns} on NSPs. At $V_a = 3$ V, the η_{lysis} was 40 to 100% 463 high on NSP-ECL chips as compared to μ PPECL devices 464 depending on enhancement factor α of NSP-ECL chips. 465 η_{lysis} was increased with increasing α on NSP-ECL chips at 466 specific V_a . η_{lvsis} of 40%, 64% and 100% were achieved at 467 $V_a = 3$ V on NSP-ECL chips with α of 5.87, 7.55 and 8.95 468 respectively. NSP-ECL chips with α of 8.95 was selected for 469 further analysis due to high η_{lysis} at low voltages. 470

471 C. Critical Values for Electric Cell Lysis

Based on the applied electric field, ECL process can be 472 divided into three phases as shown in Fig. 10. When the 473 applied electric field is below critical electric field E_{CL} , η_{lysis} 474 is very low as the electric field is not sufficient to induce 475 enough irreversible nano-pores rather reversible nanopores on 476 the cell membrane. When the applied electric field was above 477 E_{CL} , the electric field was strong enough to break down the 478 integrity of cell membrane by inducing enough irreversible 479 nano-pores. EB fluorescent molecules bound to DNA/RNA 480 inside or outside the ruptured cell membrane and lysed cells 481 exhibited orange-red fluorescence (Fig. 8(c) and (d)). At this 482 stage, a small increase in pulse amplitude V_a , more and more 483 cells lysed and η_{lysis} increased quickly (Fig. 10). η_{lysis} keep on 484 increasing by increasing electric field until η_{lysis} saturated and 485 electric field at this point defined as saturation electric field 486 E_{sat} (Fig. 10). Further increase in V_a did not improve η_{lysis} 487 but increased power consumption. 488

489 D. Electric Pulse Parameters Effects on Electric Cell Lysis

The cell lysis efficiencies were greatly influenced by applied 490 electric pulse parameters such as V_a , t_P and P_n . Higher η_{lysis} 491 can be achieved at higher pulse amplitude V_a , longer pulse 492 duration t_p and higher pulse number P_n (Fig. 10). Higher pulse 493 amplitude V_a and longer pulse duration t_p increased power 494 requirement and may also induce undesirable electrochemical 495 reactions. Electric pulse parameters should be optimized to 496 achieve high η_{lvsis} but at lower V_a and shorter t_p to minimize 497



Fig. 10. Cell lysis efficiency η_{lysis} as a function of V_a and t_P for P_n of 10 on NSP-ECL chip.

electrochemical reactions and power requirement. We have reached high η_{lysis} (~100%) at V_a of 2 V, t_p of 12 ms and P_n of 10 on NSP-ECL chip (Fig. 10). This reduction in V_a is more than ten times lower as compared to μ PPECL devices.

E. Energy Requirement for Electric Cell Lysis

The energy consumption for electric cell lysis is a crucial 504 issue especially in LOC, μ -TAS and smartphone based 505 microsystems where limited energy is available [3], [68]. This 506 energy requirement is high enough to employ complex, bulky 507 and costly power generators and equipment [16], [69]. Due to 508 high energy requirement, ECL systems usually undergo metal 509 ion dissolution, local pH variation, Joule heating, gas and 510 bubble generation and sample contamination [3], [4], [5], [17], 511 [25], [68], [70]. In order to avoid these undesirable reactions 512 on ECL devices and to integrate them on LOC, μ -TAS 513 and smartphone based microsystems; low energy consumption 514 ECL systems are highly desirable. In our approach, we utilized 515 3D nano-spikes on which electric field was enhanced due to 516 their optimized aspect-ratio. We were able to achieve cell lysis 517 at lower pulse amplitudes due to electric field enhancement. 518 The specific energy input W delivered to samples on NSP-519 ECL chips was calculated using relation: 520

$$W = V_a I P_{n.} t_p / vol \tag{3}$$

where V_a is the applied pulse amplitude, I is the electric 522 current, P_n is the pulse number, t_p is the pulse duration, and 523 vol is the sample volume (0.25 mL). A high-precision $1k\Omega$ 524 resistor was connected in series with the chip and serve as 525 the current-to-voltage converter. The resistance of the resistor 526 is too small as compared to the chip. Therefore, it can 527 be ignored in the electric current calculation. The voltage 528 signals from this resistor were measured by using a PCI 6110 529 DAQ card (National Instrument, TX, USA) and a Labview 530 program and used in the electric current calculation. The 531 specific energy input W required to achieve optimized electric 532 pulse protocol ($2V \times 12ms$ for 10 pulses) was 0.5 mJ/mL 533 (Fig. 11). The energy consumption for cell lysis on NSP-ECL 534



Fig. 11. η_{lysis} for different NSP-ECL and μ PPECL devices as a function of different electric pulse protocols and specific energy input W (mJ/mL).

TABLE III Specific Energy Requirement for Cell Lysis Using Different Methods

Ref.	Methods	Device characteristics	Treatment time	Specific energy input
[72]	Laser	Beam dia. of 100µm	60sec × 10 times	16kJ/mL
[72]	Microwave	1025W 2.45GHz	20min.	74.6kJ/mL
[72]	Mechanical solid shear	Blade dia. 40mm 120W, 3000 rpm	6min.	540kJ/mL
[72]	Thermal lysis	90°C	20min.	20.1 kJ/mL
[72]	Liquid shear ultrasonication	40W ultrasonic bath	20min.	132 kJ/mL
[73]	High voltage pulsed electric field	$L \times W = 30 \times 3 \text{mm}^2$ $d = 10 \text{mm}$	1µs	100-200 J/mL
[74]	Floatronoration	$A=0.78 \text{ cm}^2$ $d=0.3 \text{ cm}$	µs-ms	16-150 J/mL
[75]	Electroporation	$L \times W: 2.8 \times 0.6 \text{ cm}^2$ $d = 1 \text{ mm}$	100µs × 32	5-533 J/mL
This pape r	NSP-ECL device	NSP dimensions L: 350-1100nm D: 200-500nm	12ms × 10	0.05-3 mJ/mL

 $L \times W$: electrode length \times width, *d*: interelectrode distance, *A*: electrode area, *L* diameter

535	chips was 0.5-2 mJ/mL that	at is 3-9 orders	of magnitude lower
536	as compared to other cell	disintegration	methods as shown
537	in Table 3.		

Low device reliability and failure were observed in macro 538 and micro ECL devices due to high voltage operations which 539 resulted in electrolysis, gas bubble generation, Joule heating, 540 local pH variations, etc. [21]-[27]. Electrode degradation and 541 cell damage were observed during electroporation and ECL 542 processes due to gas bubbles generation which resulted in local 543 pH variations and violent hydrodynamic forces [21]-[24], 544 [59]. Gas bubble generation was observed on micro devices 545 due to high voltage operation especially above 6 V [22], [75] 546 as shown in Fig. 12(b). Although AC pulses were applied 547 on micro devices which were known to minimize electro-548 chemical reactions, still applied pulse amplitudes were high 549







Fig. 12. Cell morphologies after electric cell lysis on (a) NSP-ECL chips, bubble generation, and cell micronization was avoided and (b) on a micro ECL chip, Bubble generation was observed on micro devices [22], [75].

enough to induce gas bubble generation and electrode degra-550 dation (Fig. 12 (b)). On the other hand, on NSP-ECL chips, 551 due to the employment of NSPs, high η_{lvsis} was achieved at 552 low pulse amplitudes without bubble generation (Fig. 12(a)). 553 In addition, the cell membrane was not fully disintegrated 554 after ECL on NSP-ECL chips (Fig. 12(a)). This will avoid 555 micronization of cell debris and complex, costly and time-556 consuming downstream processes. 557

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F. Phase Diagram for Electric Cell Lysis

ECL occurs successfully when applied electric field is well 559 above its critical value E_{CL} . It is crucial to determine electric 560 pulse parameters to achieve E_{CL} as if the electric field is 561 below this critical value; cells will be reversibly electroporated 562 instead of lysed. E_{CL} was achieved at different V_a for different 563 t_p , at lower V_a for longer t_p , and at higher V_a for shorter t_p . 564 E_{CL} is defined as a critical electric field for cell lysis which 565 induces irreversible nanopores on the cell membrane and η_{lysis} 566 increases quickly. We have also determined electric pulse 567 parameters to achieve saturation electric field E_{sat} at which 568 η_{lysis} saturated. It is vital to determine E_{sat} as increasing 569 pulse parameters after this point will only result in additional 570 power hence energy consumption and micronization of cell 571 debris which is not suitable for portable LOC systems and 572 downstream processes. Using these parameters for E_{CL} and 573 E_{sat} , we have constructed "phase diagram" for ECL of HeLa 574 cells on NSP-ECL chips (Fig. 13). Phase diagram defines 575



Fig. 13. The Phase diagram for the electric cell lysis of HeLa cells on the NSP-ECL chip ($\alpha = 8.9$). The Phase diagram shows the non-ECL and ECL regions for different applied pulse durations.

the boundary for non-ECL and ECL regions for different 576 electric pulse parameters. Minimum pulse amplitude $V_{CL,min}$ 577 to achieve E_{CL} was 0.9 V for t_p of 12 ms which is more 578 than thirteen times lower as compared to μ PPECL devices. 579 Minimum pulse amplitude $V_{sat,min}$ to achieve E_{sat} was 2 V for 580 t_p of 12 ms which is more than ten times lower as compared 581 to μ PPECL devices. 582

VI. CONCLUSION

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In conclusion, we have developed a low-cost energy-584 efficient 3D nano-spike based electric cell lysis (NSP-ECL) 585 chips for efficient cell lysis at low pulse amplitudes and 586 duration. Highly-ordered self-aligned 3D Al NSP arrays with 587 controllable dimensions, i.e., length, L_{ns} , base radius, R_{ns} , 588 and pitch, P_{ns} (spike to spike distance) were fabricated 589 on low-cost commercial Al foils through simple, scalable, 590 reproducible and cost effective electrochemical anodization 591 and etching processes. The electric field has been localized 592 at NSPs due to optimized aspect-ratio with an enhancement 593 factor α as compared to micro-distant parallel plate electric 594 cell lysis (μ PPECL) chips without NSPs. NSP-ECL chips 595 have achieved high cell lysis efficiencies η_{lysis} (100%) at 596 more than ten times reduced pulse amplitudes (2 V) through 597 localized electric field E_{ns} as compared to the μ PPECL 598 chips without NSPs. These applied pulse amplitudes are 599 2-3 times reduced as compared to traditional electropora-600 tion systems used for different applications. The specific 601 energy input required to achieve 100% η_{lysis} was only in 602 the range of 0.5-2 mJ/mL which is 3-9 orders of magni-603 tude lower as compared to other cell disintegration methods 604 (5J/mL-540kJ/mL). The employment of NSPs fabricated 605 through low-cost EA&E process, optimized AC electric pulses 606 with low amplitudes and short durations minimized undesir-607 able electrochemical reactions, such as gas and bubble genera-608 tion on NSP-ECL chips which were observed on micro devices 609 due to high voltage operation. Due to the scalability of the 610 fabrication process, 3D NSPs were fabricated on small chips as 611 well as on wafers to process samples for microsystems as well 612 as for high throughput applications. These energy-efficient 613 NSP-ECL chips are highly attractive for integration with 614 other sample preparation downstream processes on portable 615 LOC and μ -TAS systems due to its low power consumption, 616

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reliability, cost-effectiveness and avoiding micronization of 617 cell debris. Based on these low voltage devices, we can 618 add additional ECL tool in a recently developed "Lab on 619 Smartphone" through which optimized EP protocols can be 620 applied to micro/nano EP chips through an open-source MCU 621 (Arduino) with an integrated Bluetooth module [48]. 622

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